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APPLICATION NO.	FIL	ING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/611,867	10/611,867 07/03/2003		Tomohiro Okumura	2003_0919A	4175
513	7590	11/02/2005		EXAMINER	
WENDER	OTH, LINI	0 & PONACK, L	ALEJANDRO MULERO, LUZ L		
2033 K STR SUITE 800	REET N. W.		ART UNIT	PAPER NUMBER	
	TON, DC	20006-1021		1763	
				DATE MAILED: 11/02/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s) OKUMURA ET AL.	
	10/611,867		
Office Action Summary	Examiner	Art Unit	
	Luz L. Alejandro	1763	
The MAILING DATE of this communication app	ears on the cover sheet with the	correspondence address	
Period for Reply			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATIO 16(a). In no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, may a reply be ting 16(a) in no event, however, howeve	N. mely filed the mailing date of this communication. ED (35 U.S.C. § 133).	
Status		•	
1)⊠ Responsive to communication(s) filed on <u>07 A</u>	oril 2005	•	
	action is non-final.		•
3) Since this application is in condition for allower		osecution as to the merits is	
closed in accordance with the practice under E		•	
	pante datajne, nece enzinin, n		
Disposition of Claims		· · · · · · · · · · · · · · · · · · ·	,
4)⊠ Claim(s) <u>1-10</u> is/are pending in the application.	·		
4a) Of the above claim(s) 5-10 is/are withdrawn	from consideration.		
5) Claim(s) is/are allowed.		*	
6)⊠ Claim(s) <u>1-4</u> is/are rejected.		*	
7) Claim(s) is/are objected to.	:	•	
8) Claim(s) are subject to restriction and/or	election requirement.		
Application Papers		•	
9) The specification is objected to by the Examine	r.		
10) The drawing(s) filed on is/are: a) acce		Examiner.	,
Applicant may not request that any objection to the			
Replacement drawing sheet(s) including the correct			
11) The oath or declaration is objected to by the Ex			
Priority under 35 U.S.C. § 119		•	
12)⊠ Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a	ı)-(d) or (f).	
a)⊠ All b)□ Some * c)□ None of:			
1. Certified copies of the priority documents			,
2. Certified copies of the priority documents			
3. Copies of the certified copies of the prior	The state of the s	ed in this National Stage	
application from the International Bureau	• • • • • • • • • • • • • • • • • • • •		ř.
* See the attached detailed Office action for a list	of the certified copies not receiv	ed.	
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Attachment(s)			
1) Notice of References Cited (PTO-892)	4) Interview Summar	y (PTO-413)	
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail [Date	
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 1003.	5) Notice of Informal 6) Other:	Patent Application (PTO-152)	
Taper No(s)/Ivian Date 1005.	o, 🗀 oner	Maria de la companya	

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DETAILED ACTION

Election/Restrictions

Applicant's election of group I in the reply filed on 4/7/05 is acknowledged.

Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).

Claims 5-10 are withdrawn from further consideration pursuant to 37 CFR

1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-2 are rejected under 35 U.S.C. 103(a) as being unpatentable over Liu et al. US 2001/0017109 in view of Colpo et al., US 6,682,630.

Liu et al. shows the invention substantially as claimed including an apparatus 10 for plasma implantation, comprising: a vacuum container 14 defining a vacuum chamber therein; a table 82 provided in the chamber for supporting a substrate to which an impurity is implanted; a plasma generating element 46 provided outside the

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chamber; a first power source 66 for applying a first high frequency electric power to the element to form a plasma in the chamber; a first detector 74 for detecting a condition of the plasma; a second detector 78 for detecting a voltage or a current in the table; and a controller 62 for controlling a first power source according to the condition of the plasma detected by the first detector and/or the voltage or the current detected by the second detector, thereby controlling an implantation concentration of the impurity to be implanted (see fig. 1 and its description).

Liu et al. does not expressly disclose a second power source for applying a second high frequency electric power to the table. Colpo et al. discloses a second power source 34 for applying a second high frequency power to the table (see fig. 2A and its description). In view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Liu et al. so as to have the second high frequency power of Colpo et al. because in such a way the ion energy to the substrate can be controlled.

Regarding claim 2, the claims are directed to method limitations instead of apparatus limitations. Since an apparatus is being claimed as the instant invention, the method teachings are not considered to be the matter at hand, since a variety of methods can be done with the apparatus. The method limitations are viewed as intended uses which do not further limit, and therefore do not patentably distinguish the claimed invention.

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Claims 3-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Liu et al. US 2001/0017109 in view of Colpo et al., US 6,682,630 as applied to claims 1-2 above, and further in view of Okumura et al., US 6,297,165.

Liu et al. and Colpo et al. are applied as above but do not expressly disclose an electrode provided adjacent the table and connected through a capacitor to the table. Okumua et al. discloses an electrode 11 provided adjacent the table 12 and connected through a capacitor 23 to the table (see fig. 3 and its description). In view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Liu et al. modified by Colpo et al. so as to include the electrode of Okumura et al. because this allows for the voltage at the substrate to be effectively monitored.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Luz L. Alejandro whose telephone number is 571-272-1430. The examiner can normally be reached on Monday to Thursday from 7:30 to 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Luz L. Alejandro Primary Examiner Art Unit 1763

October 31, 2005